

Supporting Information

Solution-Processed Vertical Field-Effect Transistor with Separated Charge Generation and Charge Transport Layers for High-Performance Near-Infrared Photodetection

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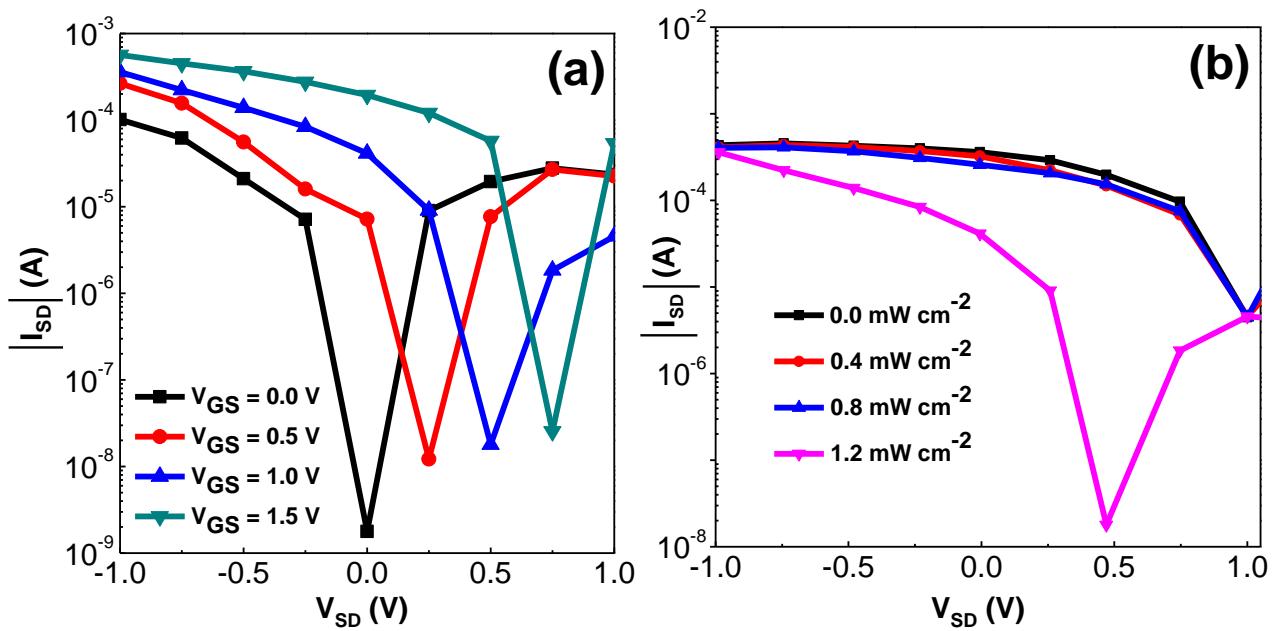
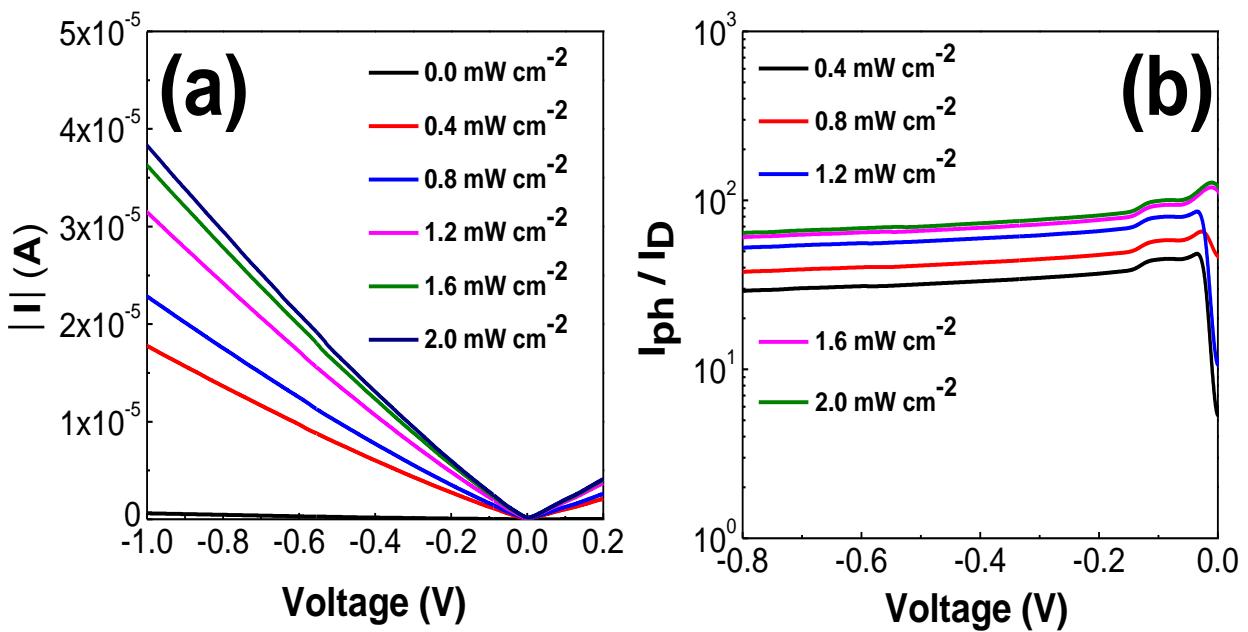


Figure S1 (a) Output characteristics (I_{SD} - V_{SD}) of the as-designed VFEPT device in the dark condition at different V_{GS} voltages. (b) Output characteristics of the device at a fixed V_{GS} of 1 V in the dark and under light irradiance of 1064 nm laser.



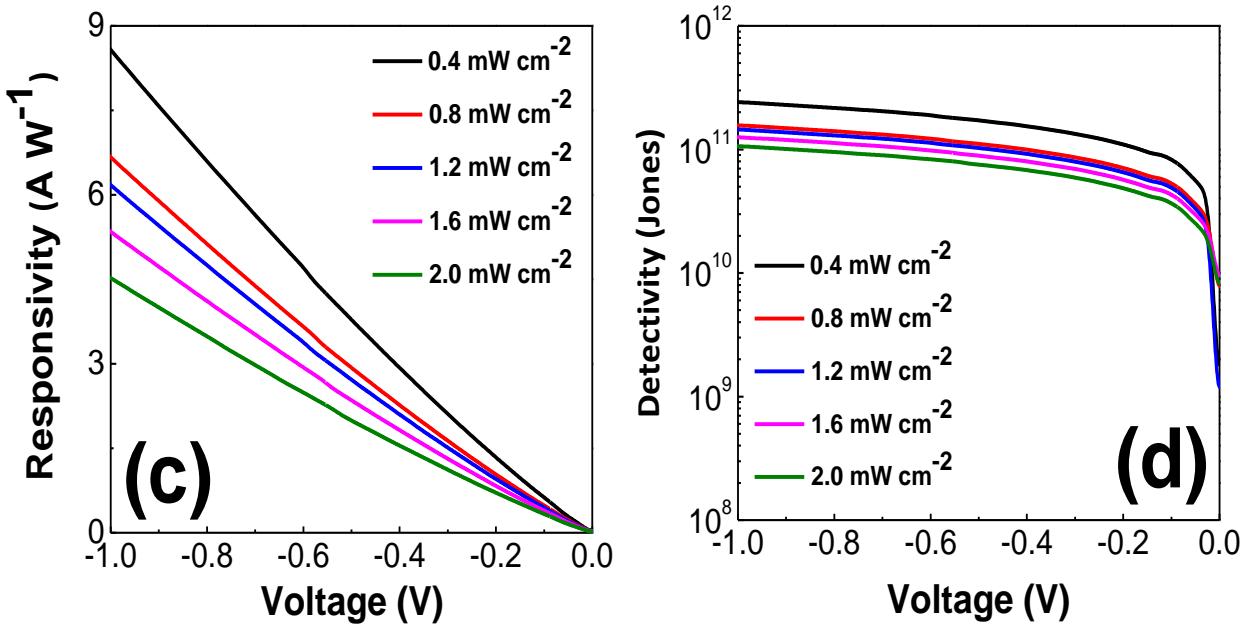
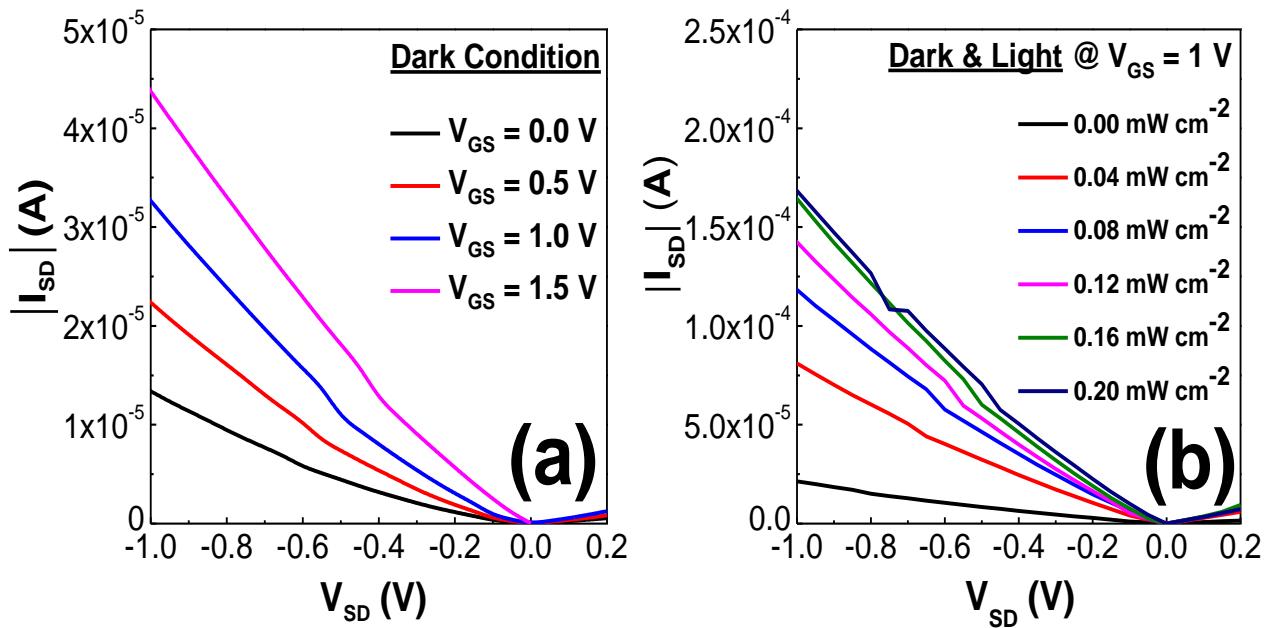


Figure S2 (a) Output characteristics of the two-terminal device (ITO/PbSe/PCBM/AgNWs) in the dark and under light irradiance of 1064 nm laser, (b) photo-to-dark current ratio, (c) the responsivity and (d) the detectivity of the two-terminal device.



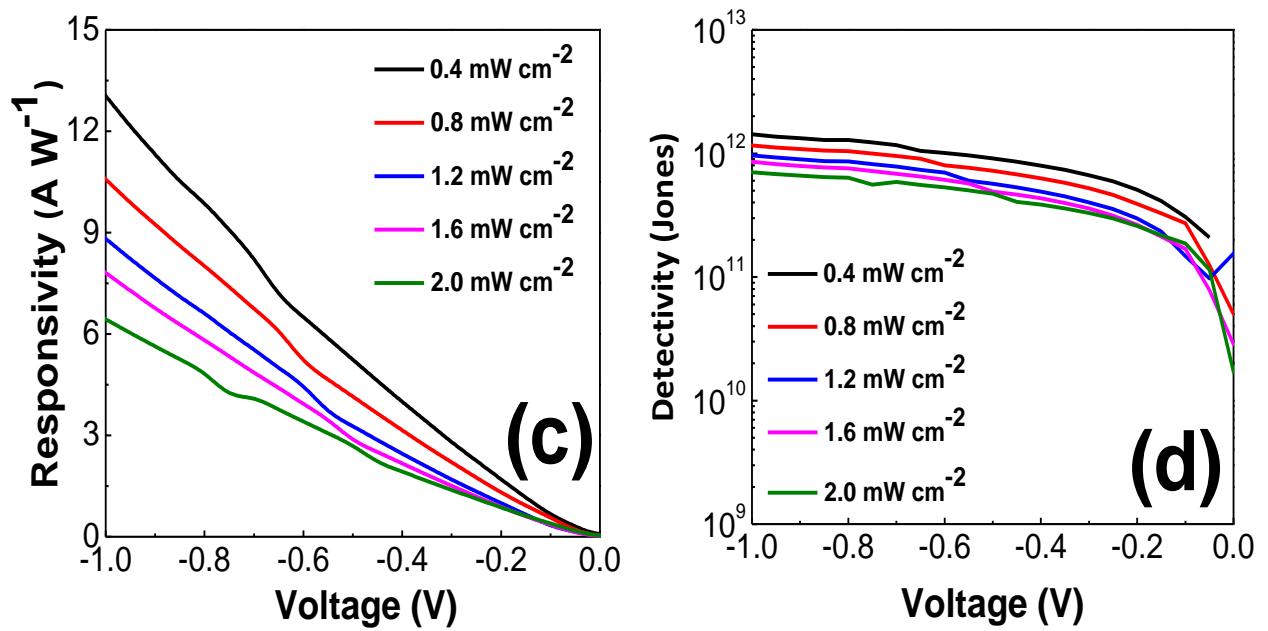


Figure S3 (a) Output characteristics (I_{SD} - V_{SD}) of the conventional VFEPT device (ITO/Ionic gel dielectric/AgNWs/PbSe QDs/AgNWs) in the dark condition at different V_{GS} voltages. (b) Output characteristics of the device at a fixed V_{GS} of 1 V in the dark and under light irradiance of 1064 nm laser. (c) The responsivity and (b) the detectivity of the conventional device as a function of V_{SD} at a fixed V_{GS} of 1 V.

Table S1 Comparison of performance of the as-designed VFEPT device with the reference devices (Figures S2 and S3) under $\sim 1 \mu\text{m}$ wavelength irradiation.

Device structure	Photo-to-dark current ratio	Responsivity (A W^{-1})	Detectivity
		@ V_{bias}	(Jones)
Two-terminal device	$\sim 10^2$	9 @ $V_{bias} = -1 \text{ V}$	$2.4 \times 10^{11} @ V = 1 \text{ V}$
Conventional VFEPT	$\sim 10^3$	13.5 @ $V_{sd} = -1 \text{ V}$ & $V_{gs} = 1 \text{ V}$	$1.1 \times 10^{12} @ V_{sd} =$ $-1 \text{ V} & V_{gs} = 1 \text{ V}$
As-designed VFEPT	$\sim 10^4$	28 @ $V_{sd} = -0.75 \text{ V}$ & $V_{gs} = 1 \text{ V}$	$1.3 \times 10^{13} @ V_{sd} =$ $0.5 \text{ V} & V_{gs} = 1 \text{ V}$

Table S2 Performance of PbX-based photodetectors under ~1 μm wavelength irradiation.

Device structure / Materials		Responsivity (A W ⁻¹)	Detectivity	References
		@ V _{bias}	(Jones)	
Photoconductor	/	PbS	6.9 @ 15 V 1060 nm	3.3×10^{11} ¹
Photoconductor	/	PbS	0.32 @ 15 V 1200 nm	2.5×10^{10} ²
Photoconductor	/	PbS	0.7 @ 15 V 1200 nm	2.5×10^{10} ³
Photodiode / PbS _x Se _{1-x}		25.8 @ -1.5 V 980 nm	1.3×10^{13}	⁴
Photodiode / ZnO:PbS		NA, 10 V 1200 nm	7×10^{13}	⁵
Phototransistor / PbSe		500 @ V _{sd} = -40 V & V _{gs} = -40 V 980 nm	5.02×10^{12}	⁶
Phototransistor / PbSe		2.93 @ V _{sd} = 5 V & V _{gs} = -20 V 980 nm	1.24×10^{13}	⁷
Phototransistor / PbSe		6×10^5 @ V _{sd} = ~10 V & V _{gs} = -100 V 400-1500 nm	NA	⁸
Phototransistor / PbSe		2×10^4 @ V _{sd} = -100 V & V _{gs} = -100 V 895 nm	NA	⁹
Phototransistor / PbSe		7×10^5 @ V _{sd} = 1 V & V _{gs} = -60 V 970 nm	7×10^{13}	¹⁰

Phototransistor / PbSe QDs	28 @ $V_{sd} = -0.75$ & $V_{gs} = 1.3 \times 10^{13}$ @ This Work
1 V	$V_{sd} = 0.5$ V &
1064 nm	$V_{gs} = 1$ V

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